IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Kurt, R. Attn. Doc. No.: NL 021426 US1

SERIAL NO.: 10/539, 362 EXAMINER: Mulvaney, E. E.

FILED: June 15, 2005 ART UNIT: 1794

CONFIRMATION No.: 7350

FOR: USE OF bI-IAYER PHOTOLITHOGRAPHIC RESISTS AS NEW
MATERIAL FOR OPTICAL STORAGE

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

<u>AMENDMENT</u>

Dear Sir:

In response to the Office Action dated August 17, 2009, the Applicant hereby submits this paper within three (3) months (until **November 17, 2009**) of the mailing date of the Office Action, and requests amendment of the above-identified application as follows wherein:

Amendments made to the Claims begin on page 2, and Remarks begin on page 11.